Fig.1

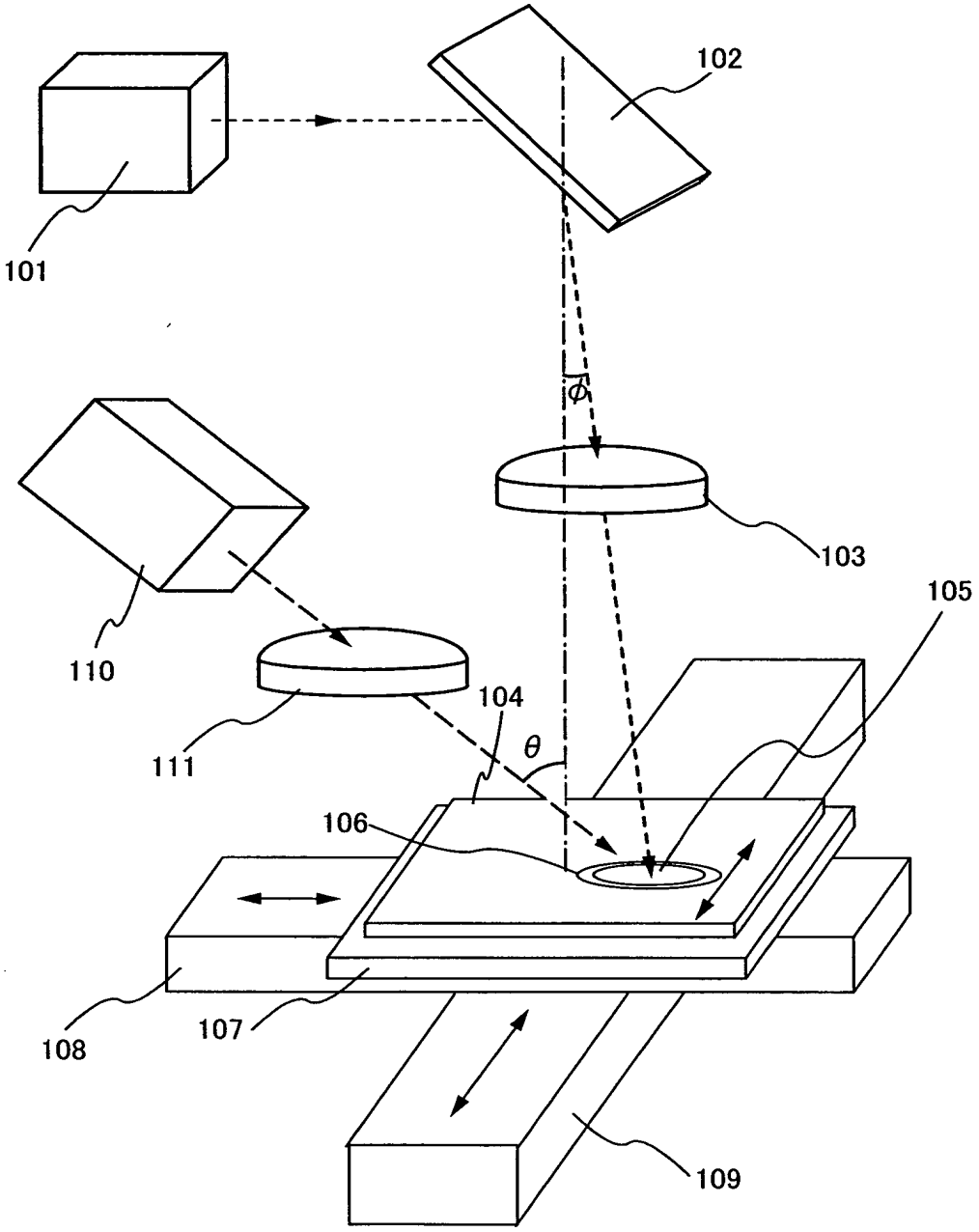


Fig. 2A

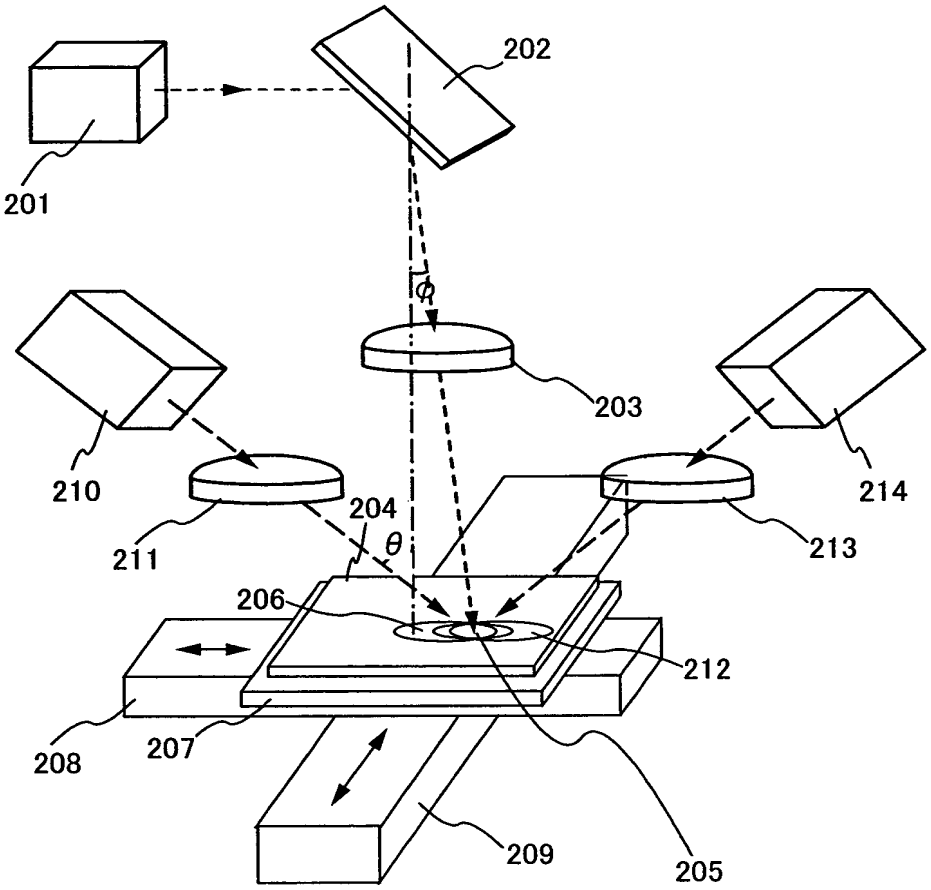
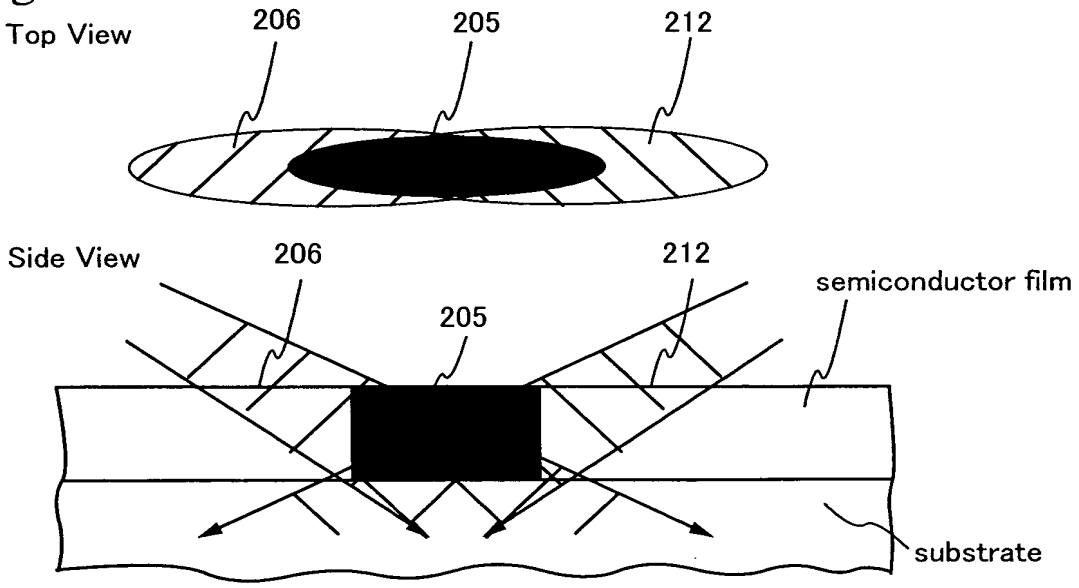

202
201
φ
203
210
214
204
θ
211
213
206
212
208
207
209
205

Fig. 2B


Top View
206
205
212
Side View
206
212
semiconductor film
205
substrate

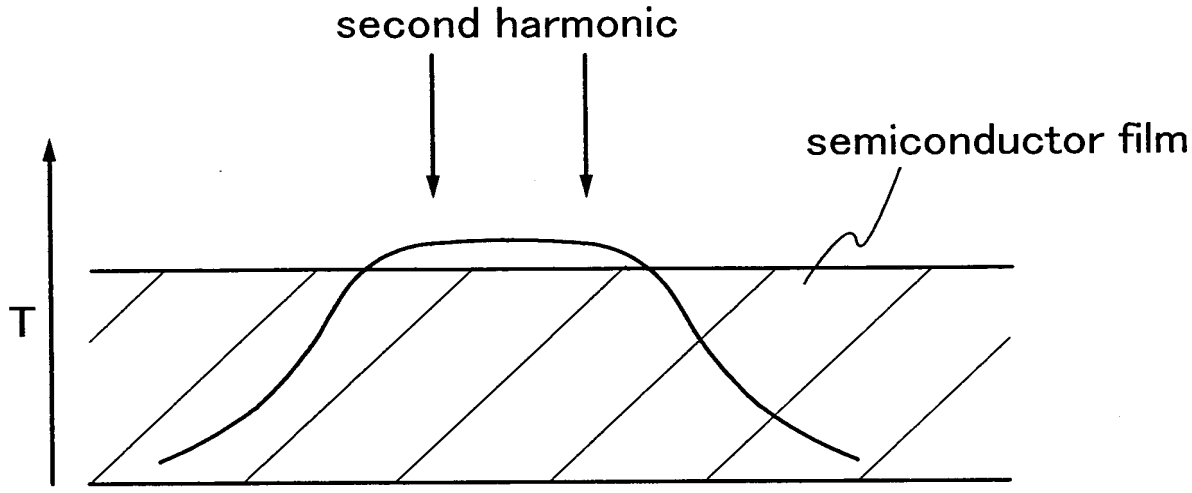

second harmonic
semiconductor film
T

Fig.3A

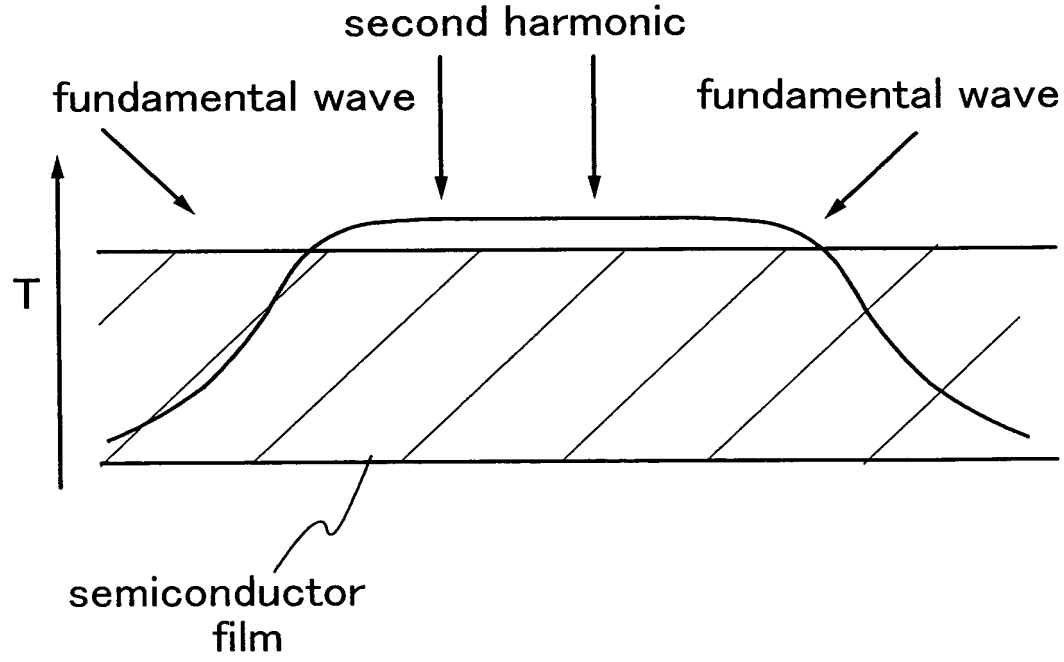

second harmonic
fundamental wave
fundamental wave
T
semiconductor
film

Fig.3B

Fig.4A

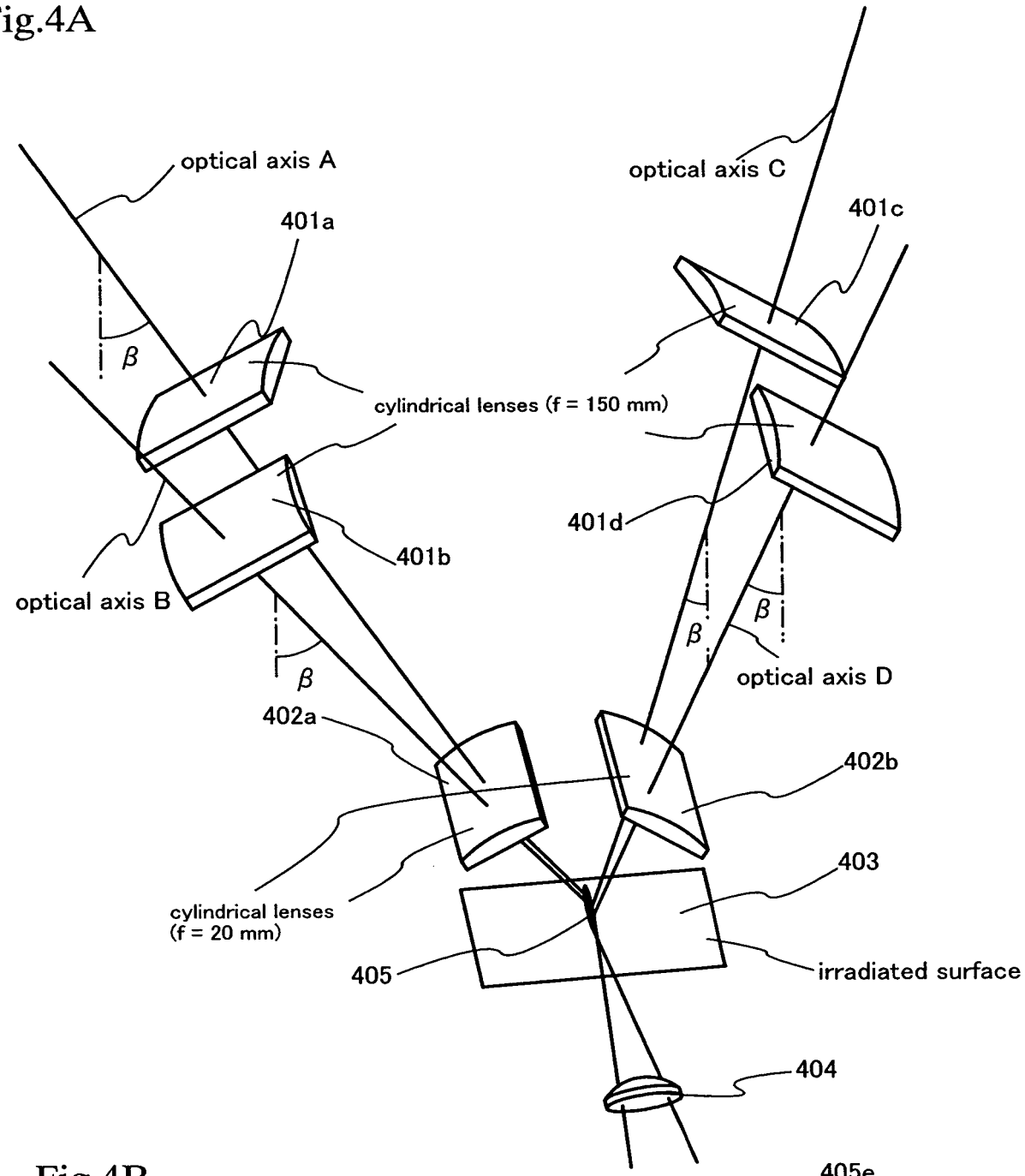

optical axis A
401a
β
cylindrical lenses (f = 150 mm)
optical axis C
401c
401d
401b
optical axis B
β
β
β
optical axis D
402a
402b
cylindrical lenses
(f = 20 mm)
403
405
irradiated surface
404

Fig.4B

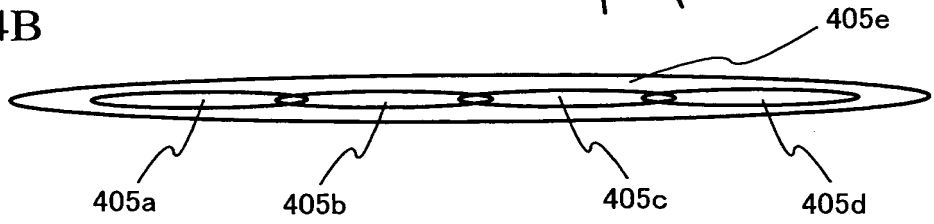

405e
405a
405b
405c
405d

Fig.5

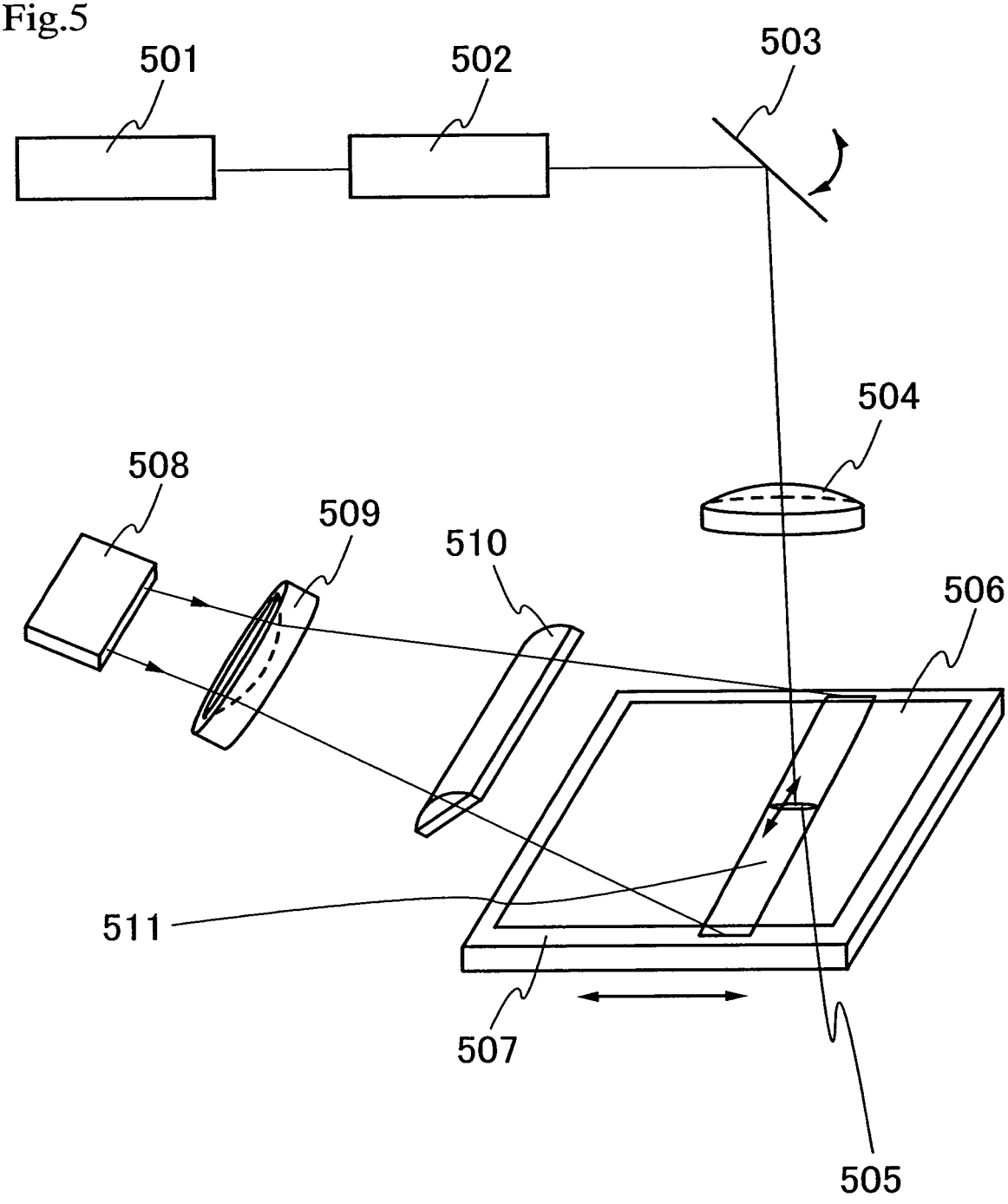
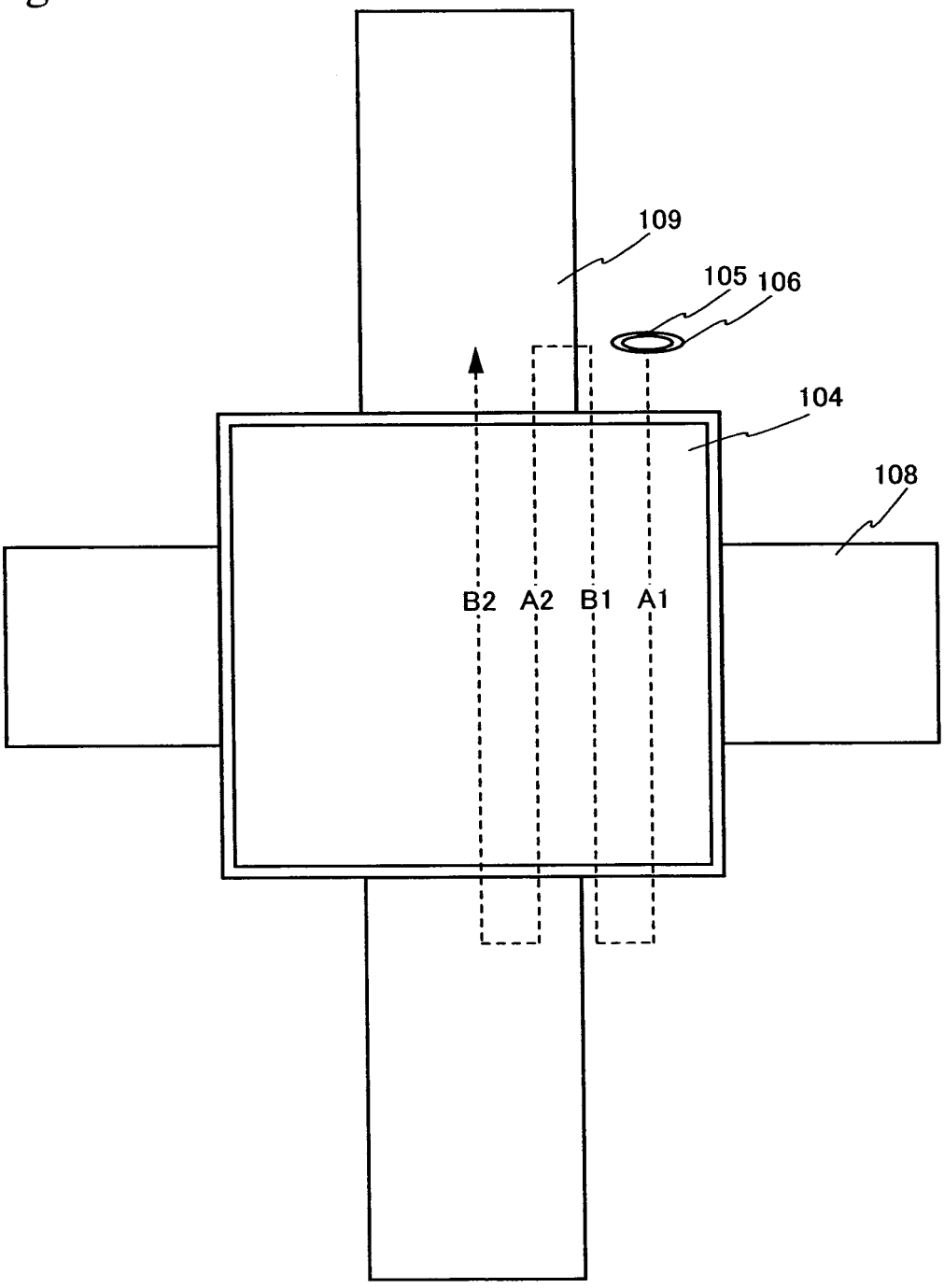


Fig.6



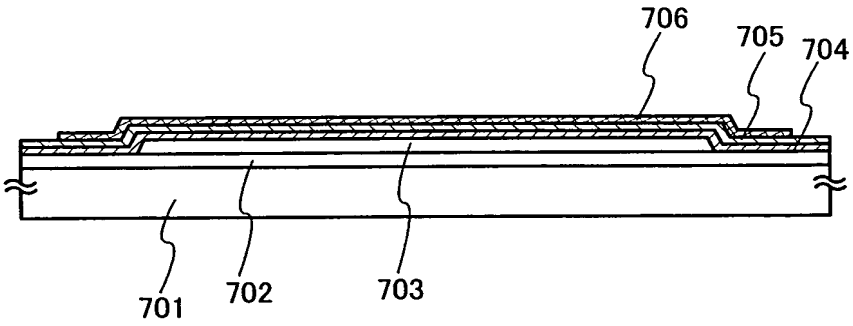


Fig.7A

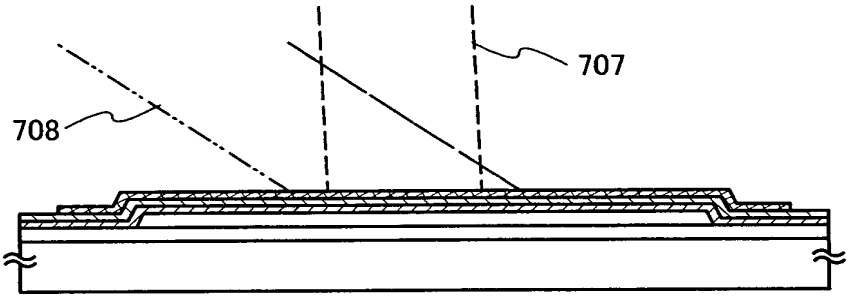


Fig.7B

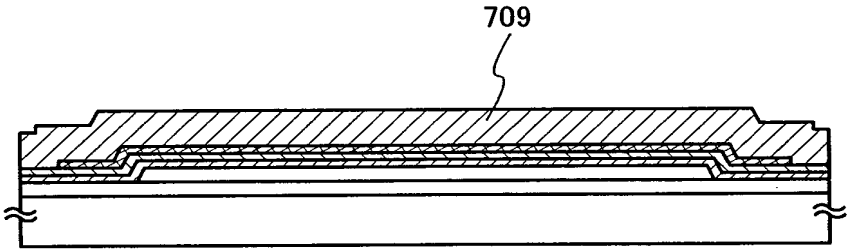


Fig.7C

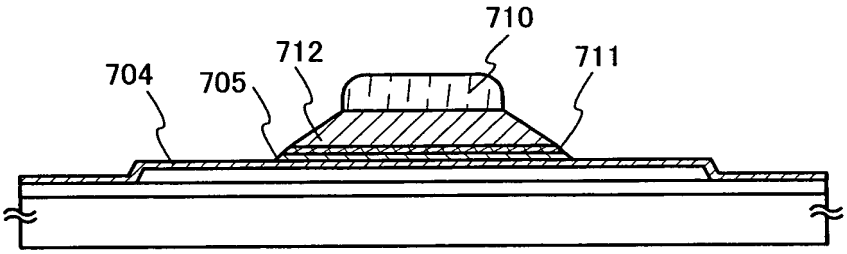


Fig.8A

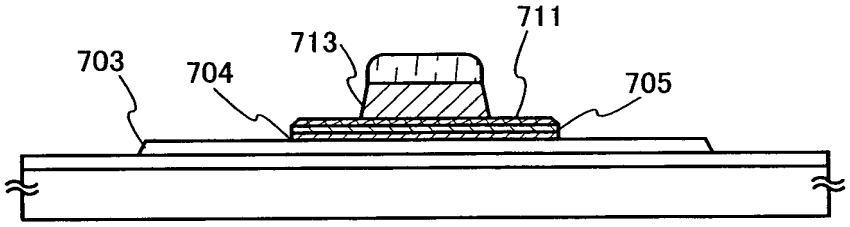


Fig.8B

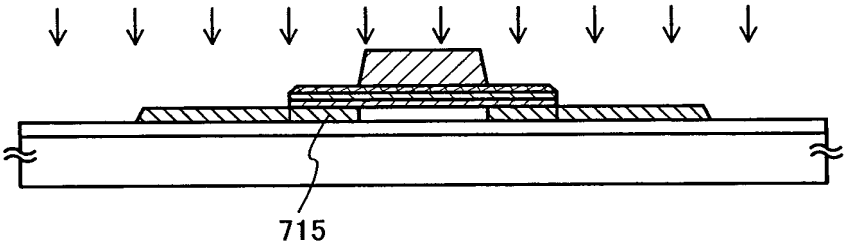


Fig.8C

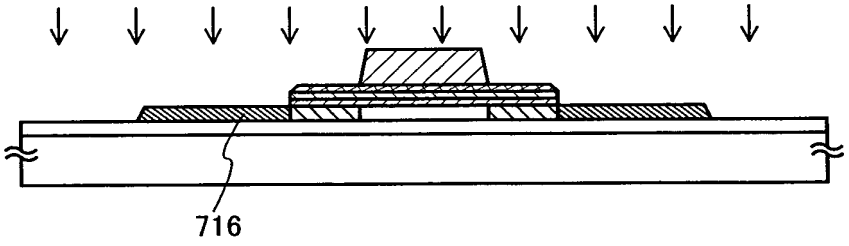


Fig.8D

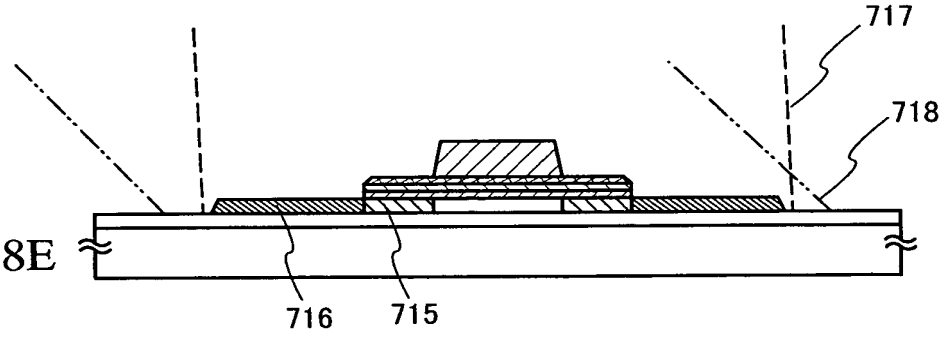


Fig.8E

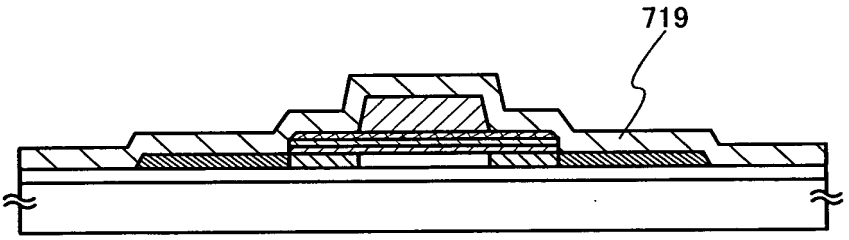


Fig.9A

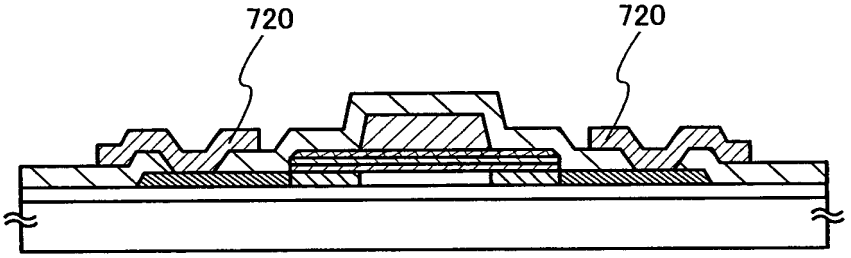


Fig.9B

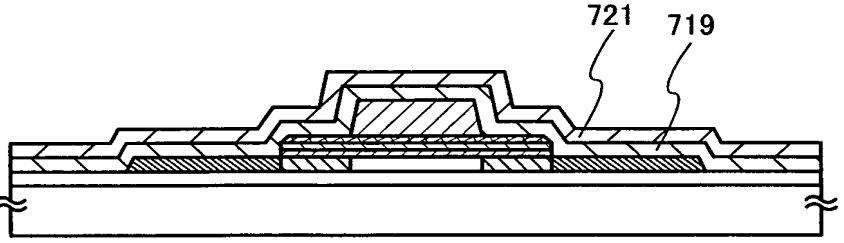


Fig.10A

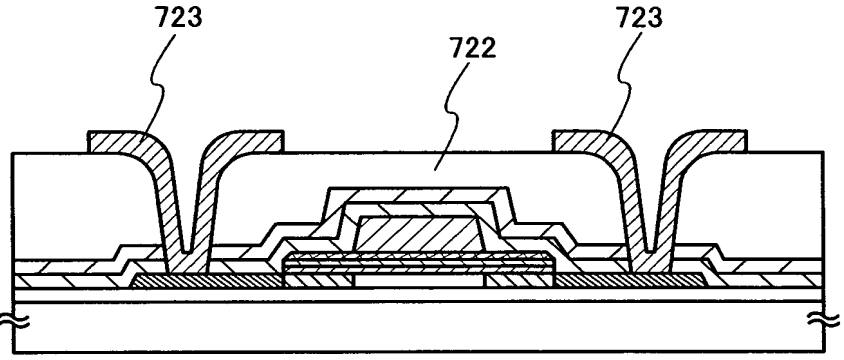


Fig.10B

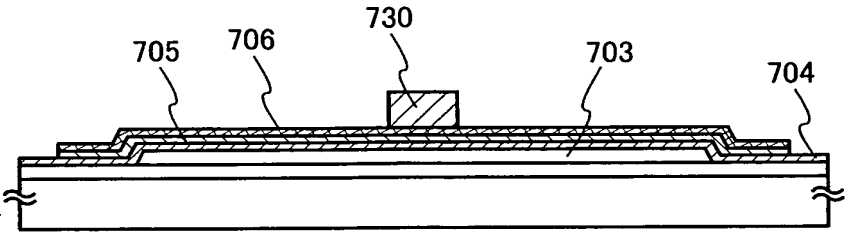


Fig.11A

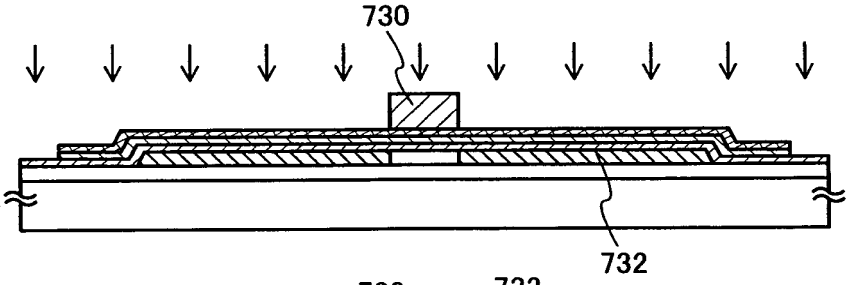


Fig.11B

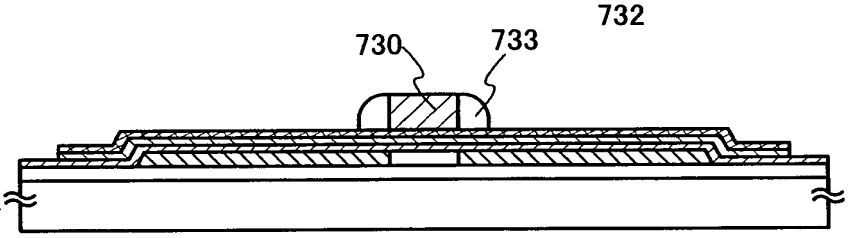


Fig.11C

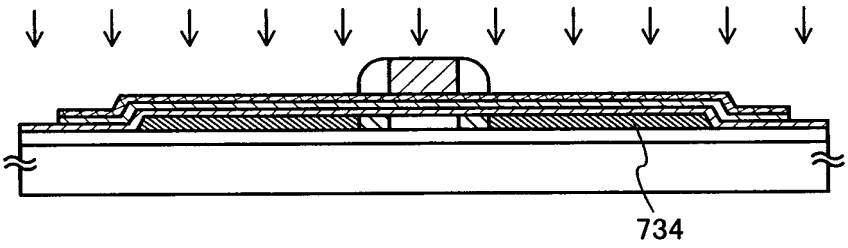


Fig.11D

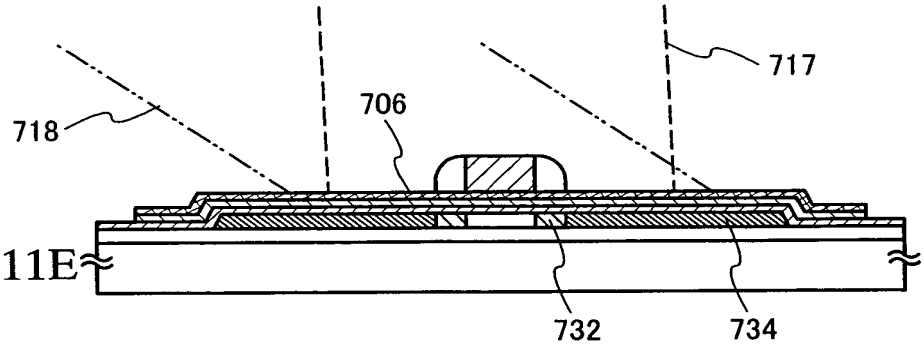


Fig.11E

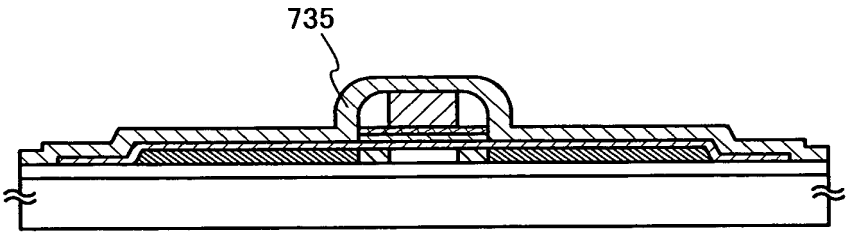


Fig.12A

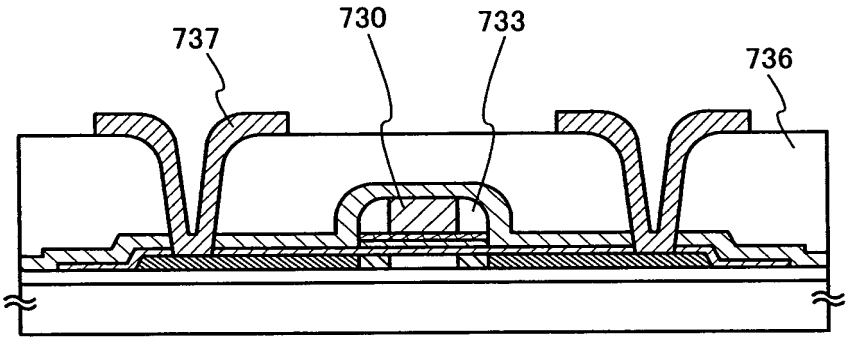


Fig.12B

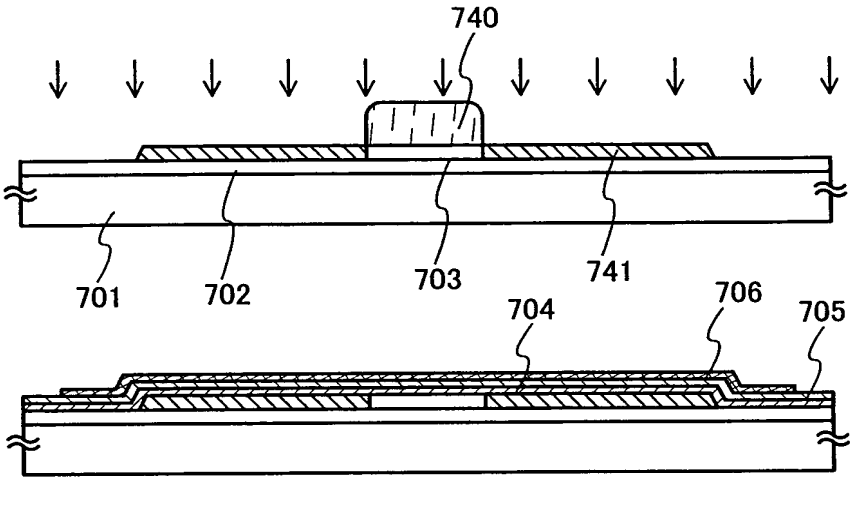


Fig.13A

Fig.13B

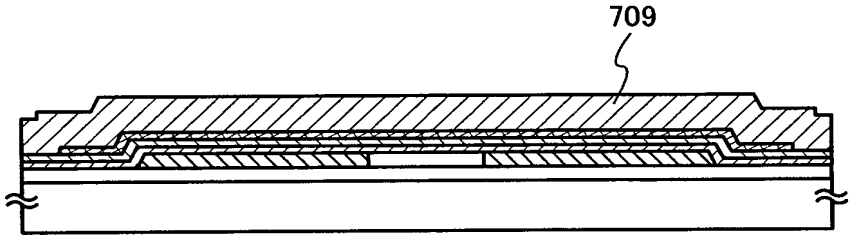


Fig.13C

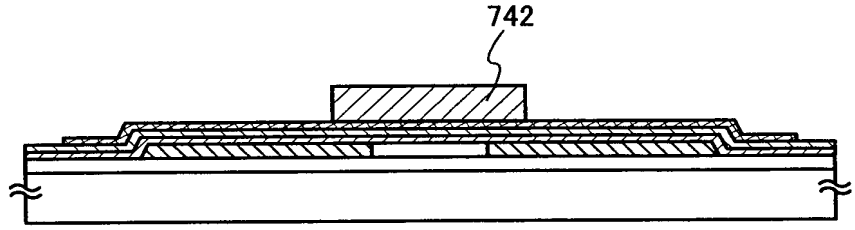


Fig.13D

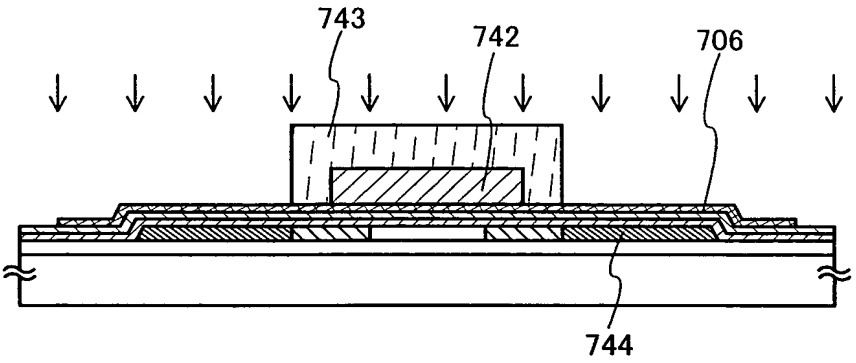


Fig.14A

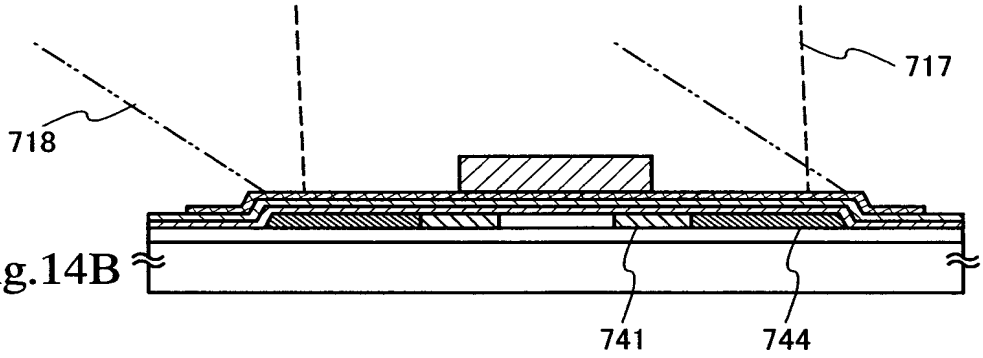


Fig.14B

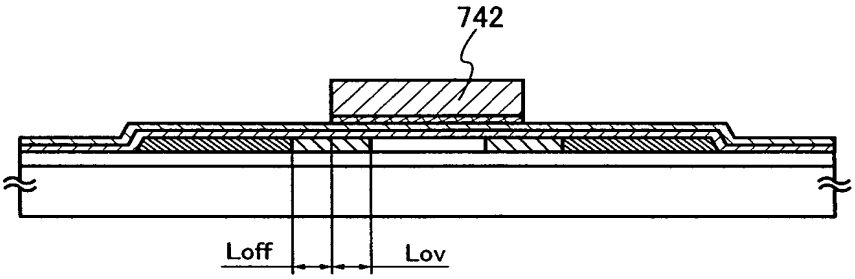


Fig.14C

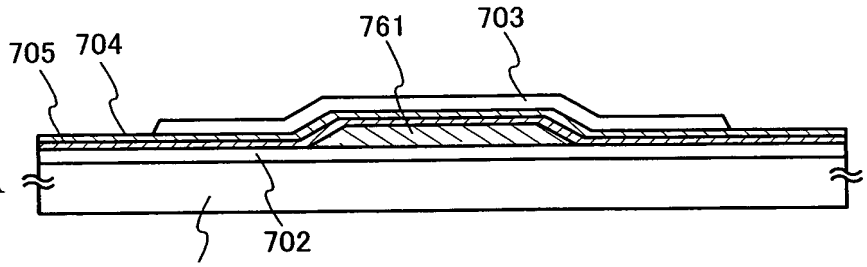


Fig.15A

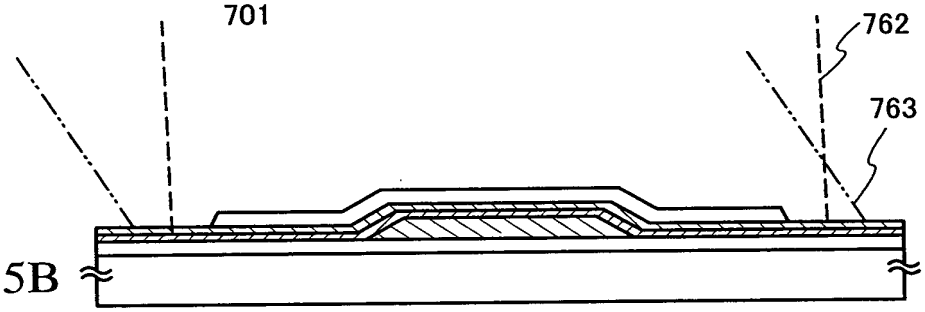


Fig.15B

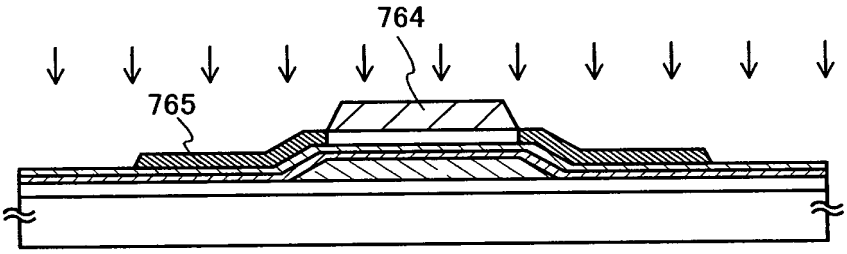


Fig.15C

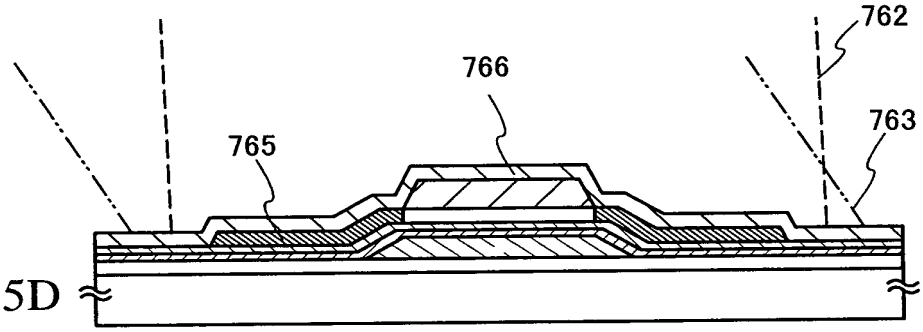


Fig.15D

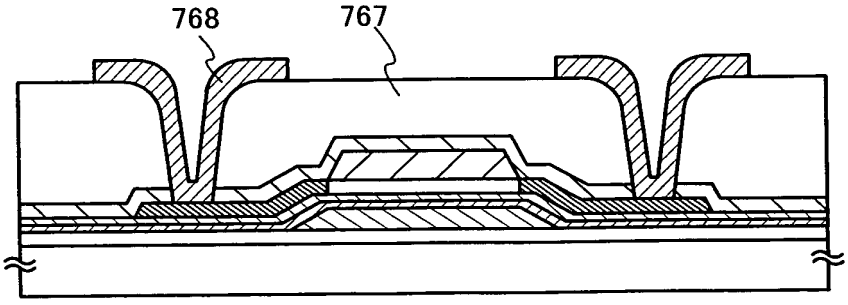


Fig.15E

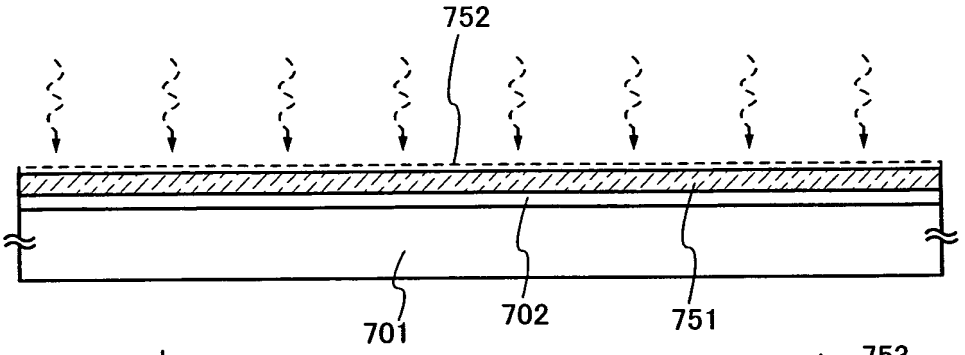


Fig.16A

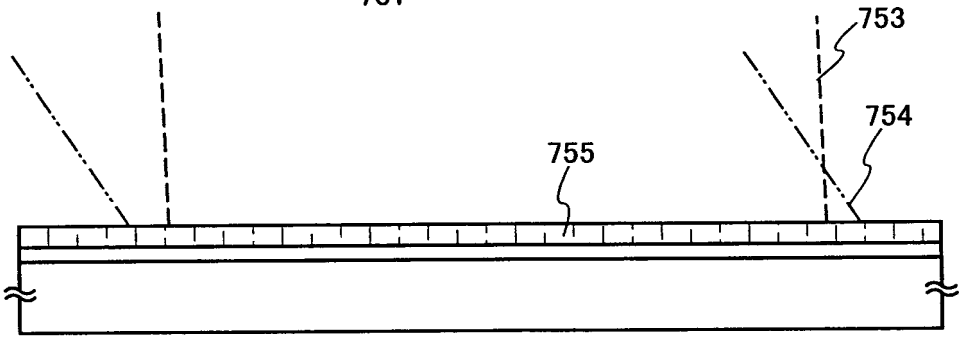


Fig.16B

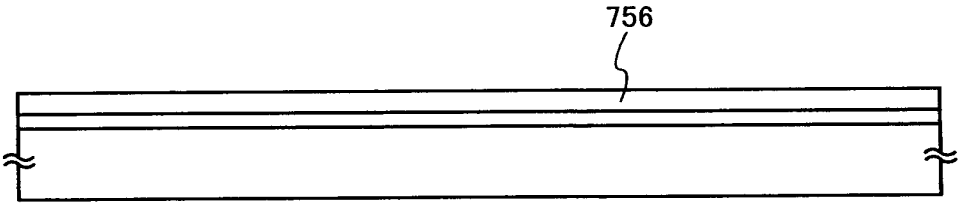


Fig.16C

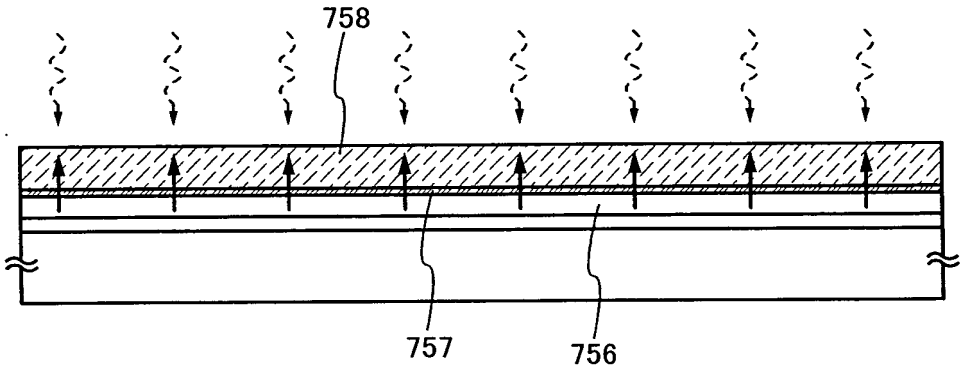


Fig.17

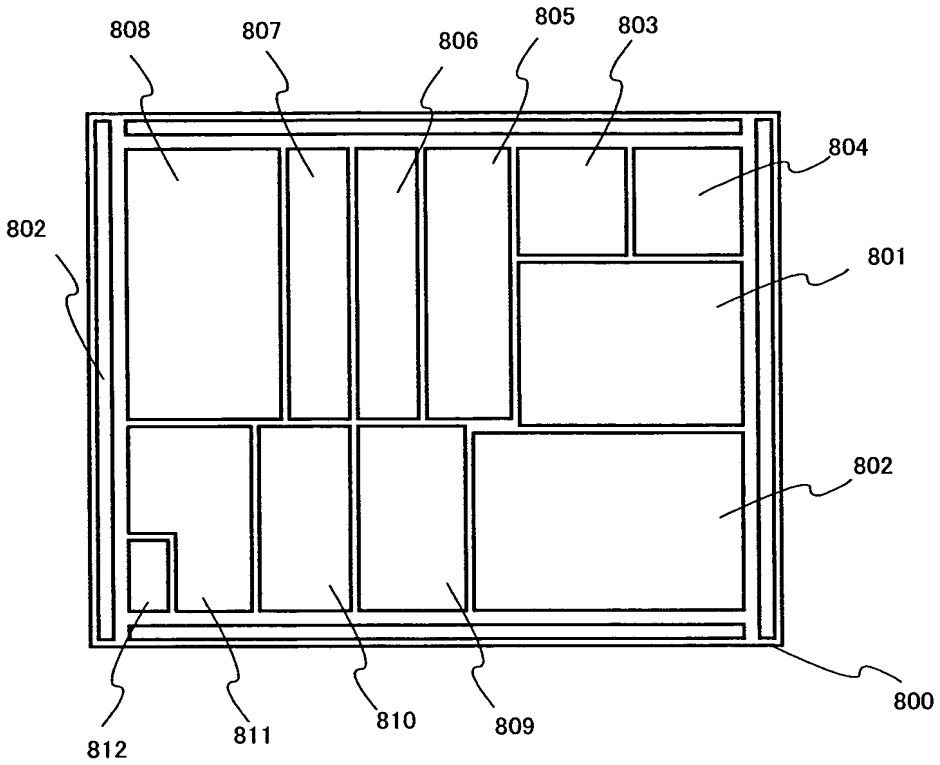


Fig.18